L Number	Hits	Search Text	DB	Time stamp
1	59519	electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/11/12 17:02
2	5883	pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/11/12 16:41
3	2509	(pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/11/12 16:53
4	15	((cathode and anode) same (projection or slope)) and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/11/12 16:47
5	46	(pixel same slope) and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/11/12 16:47
6	98	"step coverage" and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/11/12 16:47
7	138	(((pixel same slope) and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step))) or ("step coverage" and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step)))) not (((cathode and anode) same (projection or slope)) and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/11/12 16:48
8	135	(silicon or insulating or insulation or insulate) and ((((pixel same slope) and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step))) or ("step coverage" and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step)))) not (((cathode and anode) same (projection or slope)) and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/11/12 16:49

9	40	(313/$.ccls. or 428/917.ccls. or 428/690.ccls.) and ((silicon or insulating or insulation or insulate) and ((((pixel same slope) and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step))) or ("step coverage" and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step)))) not (((cathode and anode) same (projection or slope)) and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step)))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/11/12 17:02
10	5	(313/$.ccls. or 428/917.ccls. or 428/690.ccls.) and (insulat$ with slope) and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/11/12 16:58
11	3	((313/$.ccls. or 428/917.ccls. or 428/690.ccls.) and (insulat$ with slope) and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step))) not ((313/$.ccls. or 428/917.ccls. or 428/690.ccls.) and ((silicon or insulating or insulation or insulate) and ((((pixel same slope) and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step))) or ("step coverage" and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step)))) not (((cathode and anode) same (projection or slope)) and ((pixel and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)) and (insulat$ or barrier or silicon) and (projection or slope or step))))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/11/12 17:01
12	53	ichio.in. and yudasaka.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/11/12 17:02
13	8	(ichio.in. and yudasaka.in.) and (electroluminesc$ or opto-electronic or optoelectronic 428/690.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2002/11/12 17:02